


Substitute Form PTO-1449 (Modified)		U.S. Department of Commerce Patent and Trademark Office		Attorney's Docket No. 10559-839001/Intel P16714		Application No. New Application 10/648627	
Information Disclosure Statement by Applicant (Use several sheets if necessary) (37 CFR §1.98(b)) IDS filed 8/25/2003				Applicant Manish Chandhok		10/13/04	
				Filing Date		Group Art Unit Unknown 2877 10/13/04	
U.S. Patent Documents							
Examiner Initial	Desig. ID	Document Number	Publication Date	Patentee	Class	Subclass	Filing Date If Appropriate
ES	AA	6,481,003 B1	11/12/2002	Maeda			
ES	AB	6,567,155 B1	5/20/2003	Chandhok et al.			
	AC						
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						
	AJ						
	AK						

Foreign Patent Documents or Published Foreign Patent Applications								
Examiner Initial	Desig. ID	Document Number	Publication Date	Country or Patent Office	Class	Subclass	Translation	
							Yes	No
	AL							
	AM							
	AN							
	AO							
	AP							

Other Documents (include Author, Title, Date, and Place of Publication)		
Examiner Initial	Desig. ID	Document
ES	AQ	John E. Bjorkholm, "EUV Lithography—The Successor to Optical Lithography?", Intel Technology Journal Q3'98 (John.Bjorkholm@intel.com)
	AR	
	AS	
	AT	

Examiner Signature 	Date Considered 10/13/04
EXAMINER: Initials citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.	